

## **Processing of Metals, Ceramics, and Composites by Field Assisted Sintering Technology (FAST) for MHD Power**

### **Field Assisted Sintering Technology**

Field assisted sintering technology (FAST) is an emerging manufacturing technology, where heating rate as high as 1000°C/min are achieved by the simultaneous application of pressure, high temperature and high density pulsed current. In FAST, volumetric heating leads to dense compact with fewer defects at temperatures that are 200 to 250 °C lower than the temperatures used during conventional sintering. FAST is a promising solution in processing high temperature materials or composites with minimal grain growth.





Electric current distributed to the powder and die to generate heat by



Localized heating at the particles interface

## **FAST Facilities at Penn State**





- Equipment capability load : 25 Ton
- Maximum Diameter: 80 mm • Pulse current: 0 - 10KAmps
- Pulse time: 1 to 1000 ms
- Pause duration: 0 to 1000 ms
- Temperature: RT to 2400 °C
- Computerized Process control system
- Equipment capability load : 250 Ton
- Maximum Diameter: 300 mm
- Pulse current: 0-10KAmps • Pulse time: 1 to 1000 ms
- Pause duration: 0 to 1000 ms
- Temperature: RT to 2400 °C Computerized Process control system

\*\* The units are supplied by FCT company, Germany

# **Professor Jogender Singh's Research Group**











- Computerized Process control system







**SEM Image of LDS Joined to A) LDS and B) LSHR** 

Variety of materials and composites have been produced successfully by FAST. Superior properties have been observed. This technology would expand the horizon of new materials development.







<sup>0</sup>C, 75MPa, 5 min, Density =99.0%



**Ta-10%WC :** Sintered at 1600 °C, 75MPa, 5 min, Density =98.8%